

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of

Chun-Lien SU

Serial No. 10/054,962

Filed: January 25, 2002



FILE COPY

Group Art Unit: 1765

For: METHOD FOR CONTROLLING AND MONITORING A CHEMICAL
MECHANICAL POLISHING PROCESS

REQUEST FOR CORRECTED FILING RECEIPT

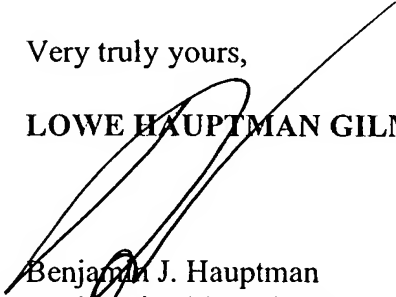
Honorable Commissioner of
Patents and Trademarks
Washington, DC 20231

Sir:

Attached is a copy of the Filing Receipt received from the U.S. Patent and Trademark Office in the above-referenced application, on which we noticed that the attorney's docket number is listed erroneously. Also attached is a copy of the Declaration listing the correct docket number, which should appear as: 4006-150. It is requested that a corrected filing receipt be issued.

Very truly yours,

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July 10, 2002



UNITED STATES PATENT AND TRADEMARK OFFICE

COMMISSIONER FOR PATENTS
UNITED STATES PATENT AND TRADEMARK OFFICE
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APPLICATION NUMBER	FILING DATE	GRP ART UNIT	FIL FEE REC'D	ATTY. DOCKET NO	DRAWINGS	TOT CLAIMS	IND CLAIMS
10/054,962	01/25/2002	1765	740	4000 150	6	15	2

CONFIRMATION NO. 8798

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REPLACEMENT FILING RECEIPT



OC000000008250512

Date Mailed: 06/07/2002

Receipt is acknowledged of this nonprovisional Patent Application. It will be considered in its order and you will be notified as to the results of the examination. Be sure to provide the U.S. APPLICATION NUMBER, FILING DATE, NAME OF APPLICANT, and TITLE OF INVENTION when inquiring about this application. Fees transmitted by check or draft are subject to collection. Please verify the accuracy of the data presented on this receipt. If an error is noted on this Filing Receipt, please write to the Office of Initial Patent Examination's Filing Receipt Corrections, facsimile number 703-746-9195. Please provide a copy of this Filing Receipt with the changes noted thereon. If you received a "Notice to File Missing Parts" for this application, please submit any corrections to this Filing Receipt with your reply to the Notice. When the USPTO processes the reply to the Notice, the USPTO will generate another Filing Receipt incorporating the requested corrections (if appropriate).

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JUN 10 2002

Assignment For Published Patent Application

Macronix International Co., Ltd.,;

Lowe, Hauptman, Gilman & Berner

Domestic Priority data as claimed by applicant

Foreign Applications

If Required, Foreign Filing License Granted 03/18/2002

Projected Publication Date: 07/31/2003

Non-Publication Request: No

Early Publication Request: No

Title

Method for controlling and monitoring a chemical mechanical polishing process

Preliminary Class

438

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Title 35, United States Code, Section 184
Title 37, Code of Federal Regulations, 5.11 & 5.15**

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